

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:)
Yu-Chin Lai, et al.) Examiner: To Be Assigned
))
Serial Number: To Be Assigned) Art Unit: To Be Assigned
))
Filed: To Be Assigned) Docket No.: P03079-D4
))
Title: HIGH REFRACTIVE INDEX AROMATIC-)
 BASED PREPOLYMER PRECURSORS))

INFORMATION DISCLOSURE STATEMENT PURSUANT TO 37 CFR 1.97(b)

**Assistant Commissioner for Patents
Washington, D.C. 20231**

Honorable Sir:

In accordance with applicants' duty under 37 CFR 1.56 with regard to the above-identified application, enclosed herewith is PTO form 1449 having listed thereon patents and publications known to the applicants.

Should there be any questions regarding this communication, please contact the undersigned at (636) 226-3340.

Respectfully submitted,



Rita D. Vacca
Reg. No. 33,624

DATE: January 26, 2004

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INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

Docket Number (Optional) P03079-D4	Application Number To be Assigned
Applicant(s) Yu-Chin Lai, et al.	
Filing Date To be Assigned	Group Art Unit To be Assigned

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		3,996,187	12/07/76	Travnicek, Edward A.	260	37	04/29/75
		3,996,189	12/07/76	Travnicek, Edward A.	260	37	03/17/76
		4,418,165	11/29/83	Polmanteer, et al.	523	210	10/07/81
		4,647,282	03/03/87	Fedorov, et al.	623	4	08/27/85
		4,868,251	09/19/89	Reich, et al.	525	479	11/19/87
		5,512,609	04/30/96	Yang, Shih-Liang S.	523	107	02/09/94
		5,623,029	04/22/97	Yang, Shih-Liang S.	525	478	06/07/95

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.